

Search Notes

Application No.

10/635,803

Examiner

D. Rutledge

Applicant(s)

OKUBO ET AL.

Art Unit

2851

SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|-----------|----------|
| 355 | 53 | 9/18/2004 | DR |
| 206 | 710, 723 | 9/18/2004 | DR |
| 414 | 217.1 | 9/18/2004 | DR |
| 414 | 931,937 | 9/18/2004 | DR |
| 414 | 416.01 | 9/18/2004 | DR |
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INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
|----------------------|----------|-----------|----------|
| 355 | 53 | 9/18/2004 | DR |
| 206 | 710,723 | 9/18/2004 | DR |
| 414 | 217.1 | 9/18/2004 | DR |
| 414 416.01, 931, 937 | | 9/18/2004 | DR |

**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
|--|-----------|------|
| pod or (mask or reticle), hold\$3 or retain\$3 or support\$3, circular or round, base, cover or top or lid, support adj block | 9/18/2004 | DR |
| cicompliant or resilient, contact, force or pressure or press or pressing, plural\$3 or three, mounting, position or location, | 9/18/2004 | DR |
| handling or safe, area or zone or region, block or protrusion or protuberance, lithography or photolithography or | 9/18/2004 | DR |
| microlithography | 9/18/2004 | DR |
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